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1999 J. Phys.: Condens. Matter 11 3355

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## Optical constants of amorphous SiO<sub>2</sub> for photons in the range of 60–3000 eV

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Received 27 July 1998, in final form 9 November 1998

**Abstract.** Optical constants of amorphous SiO<sub>2</sub> have been calculated by the Kramers–Kronig analysis in the continuous spectral region including Si L<sub>2,3</sub>, O K and Si K absorption edges from the reflection spectra measured using synchrotron radiation. It is the first experiment carried out in such a wide energy region with the same sample. It has been found that for extrapolation of the experimental curve in the high energy region, where the photon energy exceeds the ionization potential of the Si K edge, the relation  $R(E) \sim E^{-4}$  can be used for energies such that  $\theta_c < \theta/2$  at small grazing angles.

### 1. Introduction

The most perfect data on optical constants are presented in [1, 3]. Nevertheless there are many gaps in optical constants of different materials especially in the soft-x-ray region near characteristic thresholds (in the regions of anomalous dispersion). The optical constants are traditionally calculated from angular dependencies of reflection by means of Fresnel formulas. In this case, optical constants at discrete photon energies are only obtained. In order to obtain the continuous spectral dependencies of optical constants, which is the most interesting around the absorption edges (high sensitivity to the phase composition and to the atomic arrangement of the reflector), a spectral dependency of reflection and a Kramers–Kronig analysis need to be applied. In general the application of the Kramers–Kronig integral may be accompanied by some difficulties. The central problem of such calculations is a limited energy region where the reflection coefficient can be measured and extrapolations have to be used outside the spectral range of the experiment.

In the paper we report on the dispersion of optical constants of amorphous SiO<sub>2</sub> in the 60–3000 eV photon energy range. We examine the problem of the calculation of the dispersion of optical data using Kramers–Kronig analysis more closely using the reflectance measurements carried out in a very wide energy range including Si L<sub>2,3</sub>, O K and Si K absorption edges. It must be emphasized that we present the results of the first experiment carried out in such a wide energy region with the same sample and, besides, that the absolute values of the Si K reflection spectra are new too.

The purpose of the paper is also to assess the influence of the extrapolation outside the spectra range of the experiment in a high energy region on the accuracy of the values of optical constants, especially near the Si L<sub>2,3</sub> absorption edge.

## 2. Theoretical basis

### 2.1. Kramers–Kronig analysis

Because of the low polarizability of substances, the dielectric constant in the x-ray range can be conveniently represented in the form  $\varepsilon = 1 - \varepsilon_1 + i\varepsilon_2 = (n + ik)^2$ . Within the framework of the Fresnel model, the reflection amplitude of the s-polarized radiation can be written as:

$$r_s = \frac{\sin \theta - (\varepsilon - \cos^2 \theta)^{1/2}}{\sin \theta + (\varepsilon - \cos^2 \theta)^{1/2}} \quad (1)$$

where  $\theta$  is the grazing angle. In the experiment, the reflection coefficient  $R = |r|^2$  for intensities are measured. For the application of the Kramers–Kronig analysis one measures the reflectivity  $R$  at a fixed grazing angle as a function of the photon energy. The complex reflection coefficient  $r$  can be expressed in terms of its modulus  $|r| = R^{1/2}$  and its phase shift appearing after reflection of the wave at the surface of the medium. By means of the Kramers–Kronig integral one can deduce the phase shift  $\Psi(E_0)$ :

$$\Psi(E_0) = \frac{E_0}{\pi} PV \int_0^\infty \frac{\ln R(E)}{E^2 - E_0^2} dE. \quad (2)$$

Generally, the use of the Kramers–Kronig integral can involve difficulties, which are considered in [4–8]. Moreover since the integral (2) covers the whole energy range, the uncertainty in the determination of the phase shift is mainly caused by the limitation of the energy range covered by the reflectivity measurements. Outside the spectral range of the experiment, extrapolations of the reflection spectra have to be used.

### 2.2. Influence of the surface roughness on the reflection

Most of the theories, e.g. Beckmann's simple scalar theory, are based on the condition that the mean roughness height  $\sigma$  is less than the wavelength of the radiation ( $\sigma \ll \lambda$ ). The attenuation of the specular reflection, in this case, is generally given by the so-called Debye–Waller formula according to that the total integrated scattering only depends on the value of the rms roughness height  $\sigma$ . This theoretical condition is violated in the spectral range being considered.

In the strict sense, the total integrated scattering depends on both the value of the rms roughness height  $\sigma$  and the radius of correlation  $a$  [9–11]. According to [11] a smooth surface can be characterized by only fairly large radius of correlation  $a$

$$a \gg \frac{\lambda}{\pi \theta_c^2}$$

$\theta_c$  being the critical angle. It should be emphasized that roughnesses with large radii of correlation do not contribute to radiation absorption and do not change the total radiation fluxes on the two sides of the interface. They only redistribute the intensity between the specular and scattered reflections. A distinction needs to be drawn between the total integrated scattering at small and large glancing angles. At the large glancing angles

$$\frac{\pi a \theta^2}{\lambda} \gg 1 \quad \frac{\pi a \theta_c^2}{\lambda} \gg 1$$

the total integrated scattering depends only on the value of the rms roughness height  $\sigma$  whereas it depends on the rms roughness height  $\sigma$  as well as the radius of correlation  $a$  at the small glancing angles [12]

$$\frac{\pi a \theta^2}{\lambda} \ll 1 \quad \frac{\pi a \theta_c^2}{\lambda} \gg 1.$$

From the above reasoning the attenuation of the specular reflection can be written as follows [12]:

$$R = R_F \exp \left[ - \left( \frac{4\pi}{\lambda} \sigma \sin \theta \right)^2 \right] \quad \text{at large glancing angle } \theta \quad (3a)$$

$$R = R_F \exp \left[ - \left( \frac{2\pi}{\lambda} \right)^{3/2} \frac{\sigma^2}{\sqrt{a}} \theta \right] \quad \text{at small glancing angle } \theta \quad (3b)$$

where  $R$  is the reflectivity of a rough surface,  $R_F$  is the reflectivity of a perfect surface,  $\sigma$  is rms height,  $a$  is radius of correlation.

### 3. Experimental procedure and sample

The angular and spectral dependencies of reflectivity near the Si K absorption edge were carried out in a reflectometer set-up on the SB3 synchrotron beamline 'MOGOTOX' (monochromator and goniometer for x-ray optics treatment) of the Super-ACO storage ring of LURE at Orsay. Figure 1 presents the MOGOTOX device; it is composed of two chambers located at 11 and 13 m from the source respectively. The first one contains the entrance slit and is used as a vacuum buffer between the ring and the second measurement chamber. The second chamber contains a filter holder, an energy low-pass filter, a double-crystal monochromator, a  $\theta$ - $2\theta$  goniometer and a detector. The first crystal of the monochromator has rotational and translational adjustments whereas the second one has only rotational adjustment. The crystal rotation can be varied from 5 to 85 degrees. This allows us to cover the energy range from 0.8 to 8 keV, using different crystal pairs. (111) InSb crystal sheets, the reflectivity of which is close to 60%, were used in the experiment. The energy resolution near Si K was better than

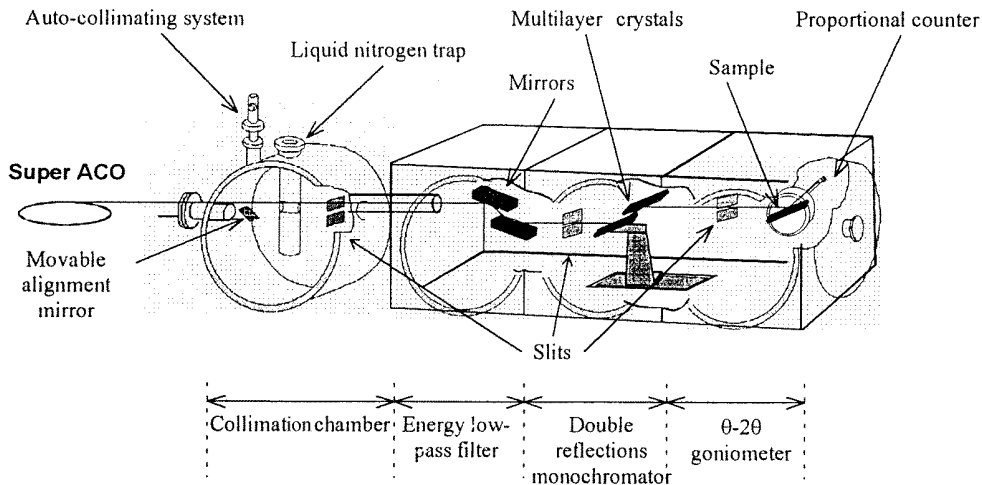


Figure 1. MOGOTOX device: experimental set-up for x-ray optics and detector calibration.

0.8 eV. The  $\theta$ - $2\theta$  goniometer has several degrees of freedom that permit us to locate the sample relative to the incident beam. The detector is a gas flow proportional counter closed with a system composed with a polypropylene window supported by a metallic grid. It works with a 90%/10% argon/methane mixture. High spectral purity was achieved by using the detector in the proportionality mode with a single channel analyser.

A sample with an  $\text{SiO}_2$  layer of 120 nm thickness on a top of an Si substrate was investigated. The Si substrate is a 0.8 mm thick disc of (111) single-crystal silicon of p type; the diameter of the disc is 7.6 cm. The value of rms roughness is smaller than 1 nm. The sample was prepared by a dry oxidation method at about 1050 °C. In this case the surface of the sample is formed in the process of spontaneous growth of dioxide on the crystalline silicon plate.

## 4. Results and discussion

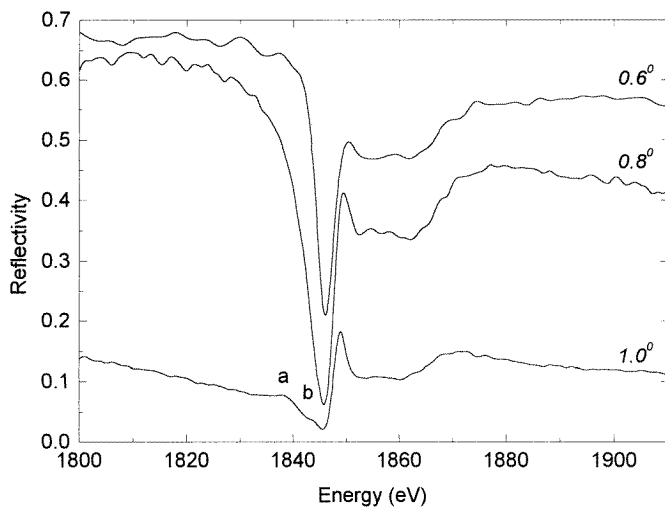
### 4.1. Reflection spectra

Figure 2 shows the Si K reflection spectra  $R(E)$  obtained for different glancing angles ( $\theta = 0.6^\circ, 0.8^\circ, 1^\circ$ ). These spectra are similar in shape to the reflection spectra obtained in [13]. It should be stressed that spectra measured in [13] were obtained in arbitrary units.

Due to the limited size of the sample and the size of the beam, the reflected radiation is only partially detected at more grazing angles. As can be seen in figure 2, the spectra are similar in number of features and in their energy positions. The maxima a and b in the spectrum at  $1^\circ$  are caused purely by interference.

The reflection spectrum at the grazing angle of  $0.6^\circ$  measured in the wide energy range 1800–3000 eV was chosen to calculate the optical constants. In this case, the  $\text{SiO}_2$  layer is thick enough for radiation almost not to penetrate through it. This spectrum was joined with the data obtained for the same sample in the soft-x-ray region (50–900 eV) [14, 15].

Recall that the atoms in condensed systems can be considered as independent scattering dipoles (the effect of electron charge redistribution in solids on the tensor of atomic scattering factor in the normal dispersion region is small enough to be neglected) in the range of normal



**Figure 2.** Si K reflection spectra of  $\text{SiO}_2$  for grazing angles  $\theta = 0.6^\circ, 0.8^\circ, 1^\circ$ .

**Table 1.** Optical constants for amorphous SiO<sub>2</sub> prepared by a dry oxidation method at ~1050 °C (mass density  $\rho$  was 2.3 g cm<sup>-3</sup>) calculated from spectral dependency of reflection using Kramers–Kronig analysis. Data calculated from angular dependencies of reflection [14] are given in brackets.

eV	Å	<i>n</i>	<i>k</i>
65.0	190.73	0.957 93	$2.727 \times 10^{-2}$
69.0	179.68	0.959 61	2.405
73.0	169.83	0.962 37	2.097
77.0	161.01	0.965 66	1.848
81.0	153.06	0.968 20	1.664
84.5	146.72	0.970 44	1.509
87.1	142.34	0.971 86	1.403
90.0	137.75	0.973 85	1.269
92.5	134.03	0.975 12	1.167
95.0	130.50	0.976 65	$1.076 \times 10^{-2}$
98.0	126.51	0.978 79	$9.574 \times 10^{-3}$
99.5	124.60	0.979 85	9.143
100.0	123.98	0.980 26	9.006
103.0	120.36	0.983 11	8.257
104.3	118.86	0.985 06	7.927
104.4	118.75	0.985 24	7.881
104.5	118.64	0.985 50	7.841
104.6	118.52	0.985 80	7.813
104.7	118.41	0.986 13	7.879
104.8	118.30	0.986 38	7.865
104.9	118.18	0.986 76	7.830
105.0	118.07	0.987 24	7.902
105.1	117.96	0.987 69	8.071
105.2	117.85	0.988 18	8.311
105.4	117.62	0.989 21	$9.158 \times 10^{-3}$
105.5	117.51	0.989 60	$1.001 \times 10^{-2}$
105.6	117.40	0.989 68	1.091
105.7	117.29	0.989 53	1.180
105.9	117.07	0.988 38	1.288
106.0	116.96	0.987 74	1.291
106.1	116.85	0.987 35	1.276
106.2	116.74	0.987 20	1.258
106.3	116.63	0.987 16	1.250
106.4	116.52	0.987 11	1.251
106.5	116.41	0.986 98	1.244
106.6	116.30	0.986 93	1.224
106.7	116.19	0.987 09	1.190
106.8	116.08	0.987 51	1.171
106.9	115.97	0.988 06	1.176
107.0	115.87	0.988 57	1.197
107.1	115.76	0.989 13	1.239
107.4	115.43	0.989 92	1.446
107.5	115.33	0.989 87	1.532
107.9	114.90	0.988 03	1.843
108.0	114.79	0.987 13	1.914
108.1	114.69	0.986 04	1.945
108.2	114.58	0.985 17	1.961
108.3	114.47	0.984 18	1.964
108.4	114.37	0.983 23	1.942
108.5	114.26	0.982 38	1.925
108.9	113.84	0.979 57	1.683

**Table 1.** (Continued)

eV	Å	<i>n</i>	<i>k</i>
109.0	113.74	0.97926	1.613
109.1	113.63	0.97905	1.526
109.2	113.53	0.97907	1.448
109.3	113.43	0.97916	1.384
110.1	112.60	0.98131	1.060
110.2	112.50	0.98167	1.048
110.3	112.40	0.98195	1.046
110.4	112.30	0.98217	1.041
110.5	112.20	0.98243	1.036
110.6	112.09	0.98266	1.041
110.7	111.99	0.98279	1.038
110.8	111.89	0.98301	1.038
111.1	111.59	0.98345	1.047
111.2	111.49	0.98358	1.046
111.6	111.09	0.98394	1.068
112.5	110.20	0.98452	1.071
113.4	109.33	0.98520	1.113
116.5	106.42	0.98388	$1.126 \times 10^{-2}$
119.7	103.57	0.98594	$9.207 \times 10^{-3}$
122.9	100.88	0.98813	$1.028 \times 10^{-2}$
126.2	98.24	0.98811	1.196
129.6	95.66	0.98707	1.249
133.1	93.14	0.98609	1.185
136.7	90.69	0.98564	$1.070 \times 10^{-2}$
140.4	88.30	0.98575	$9.498 \times 10^{-3}$
144.2	85.97	0.98637	8.448
148.1	83.71	0.98706	7.671
152.2	81.46	0.98805	7.183
156.3	79.32	0.98886	7.091
160.5	77.24	0.98808	7.003
164.8	75.23	0.98887	6.306
169.3	73.23	0.98936	5.898
173.9	71.29	0.98982	5.558
178.6	69.41	0.99014	5.165
183.5	67.56	0.99061	4.840
188.5	65.77	0.99104	4.607
193.5	64.07	0.99133	4.430
199.0	62.30	0.99154	4.171
204.0	60.77	0.99181	3.883
209.5	59.18	0.99209	3.592
215.5	57.53	0.99238	3.280
221.0	56.10	0.99268	2.985
227.0	54.61	0.99301	2.714
233.0	53.21	0.99334	2.481
239.5	51.76	0.99368	2.257
246.0	50.40	0.99399	2.068
252.5	49.10	0.99431	1.873
259.5	47.77	0.99464	1.715
266.5	46.52	0.99496	1.625
273.5	45.33	0.99523	1.504
450.0	27.55	[0.99817]	[3.535]
500.0	24.80	[0.99865]	[2.545]
510.0	24.31	[0.99875]	[2.405]

**Table 1.** (Continued)

eV	Å	<i>n</i>	<i>k</i>
520.0	23.84	[0.998 88]	[2.315]
524.7	23.63	0.998 94	2.457
527.7	23.49	0.999 01	2.492
529.7	23.40	0.999 08	2.533
531.2	23.34	0.999 16	2.859
531.7	23.32	0.999 18	3.033
532.2	23.29	0.999 19	3.229
532.7	23.27	0.999 23	3.100
533.2	23.25	0.999 29	3.322
533.7	23.23	0.999 31	3.660
534.7	23.19	0.999 39	4.230
535.2	23.16	0.999 42	4.662
535.7	23.14	0.999 46	5.659
536.2	23.12	0.999 46	6.741
536.7	23.10	0.999 46	7.695
537.2	23.08	0.999 42	$8.772 \times 10^{-4}$
538.2	23.04	0.999 23	$1.031 \times 10^{-3}$
538.7	23.01	0.999 12	1.040
539.2	22.99	0.999 03	$1.023 \times 10^{-3}$
539.7	22.97	0.998 93	$9.732 \times 10^{-4}$
540.2	22.95	0.998 91	9.703
540.7	22.93	0.998 84	9.439
541.2	22.91	0.998 80	8.431
541.7	22.89	0.998 81	8.337
542.2	22.87	0.998 79	8.267
542.7	22.84	0.998 75	7.960
544.2	22.78	0.998 74	7.130
546.2	22.70	0.998 74	6.345
548.2	22.61	0.998 78	5.644
549.2	22.57	0.998 79	5.476
550.7	22.51	0.998 83	5.299
565.7	21.92	0.998 77	6.376
580.7	21.35	0.998 80	4.791
595.7	20.81	0.998 86	4.373
610.7	20.30	0.998 90	4.336
620.7	19.97	0.998 90	4.118
630.7	19.66	0.998 92	3.845
640.7	19.35	0.998 94	3.618
655.5	18.91	0.998 98	3.271
670.5	18.49	0.999 02	2.983
685.5	18.09	0.999 05	2.724
700.0	17.71	0.999 09	2.545
715.0	17.34	0.999 12	2.401
730.0	16.98	0.999 15	2.265
745.0	16.64	0.999 18	2.113
760.0	16.31	0.999 21	1.966
775.0	16.00	0.999 24	1.827
790.0	15.69	0.999 26	1.699
805.0	15.40	0.999 29	1.592
820.0	15.12	0.999 31	1.491
835.0	14.85	0.999 32	1.356
850.0	14.59	0.999 37	1.220
865.0	14.33	0.999 38	1.132
880.0	14.09	0.999 40	1.113



**Table 1.** (Continued)

eV	Å	<i>n</i>	<i>k</i>
895.0	13.85	0.999 42	$1.048 \times 10^{-4}$
910.0	13.62	0.999 44	$9.946 \times 10^{-5}$
925.0	13.40	0.999 46	9.593
940.1	13.19	0.999 47	9.062
955.1	12.98	0.999 49	8.539
970.1	12.78	0.999 51	8.101
985.1	12.59	0.999 52	7.687
1000.1	12.40	0.999 53	7.294
1050.1	11.81	0.999 58	6.180
1100.1	11.27	0.999 61	5.246
1150.1	10.78	0.999 65	4.485
1200.1	10.33	0.999 68	3.863
1250.1	9.92	0.999 70	3.348
1300.1	9.54	0.999 73	2.915
1355.1	9.15	0.999 75	2.520
1405.1	8.82	0.999 77	2.221
1455.1	8.52	0.999 78	1.966
1500.1	8.26	0.999 80	1.766
1550.1	8.00	0.999 81	1.574
1600.1	7.75	0.999 82	1.406
1645.1	7.54	0.999 83	1.273
1700.1	7.29	0.999 85	$1.128 \times 10^{-5}$
1750.1	7.08	0.999 86	$9.898 \times 10^{-6}$
1795.1	6.91	0.999 87	8.911
1840.1	6.738	0.999 90	8.990
1842.6	6.728	0.999 91	8.784
1842.7	6.728	0.999 91	8.802
1842.8	6.728	0.999 91	8.851
1842.9	6.727	0.999 91	8.934
1843.4	6.726	0.999 92	$9.955 \times 10^{-6}$
1844.6	6.721	0.999 93	$1.822 \times 10^{-5}$
1845.8	6.717	0.999 95	4.418
1846.0	6.716	0.999 96	5.481
1846.1	6.716	0.999 96	6.145
1846.2	6.715	0.999 96	6.889
1846.3	6.715	0.999 96	7.708
1846.4	6.715	0.999 96	8.579
1846.5	6.714	0.999 95	$9.470 \times 10^{-5}$
1847.0	6.712	0.999 91	$1.276 \times 10^{-4}$
1847.1	6.712	0.999 90	1.289
1847.2	6.712	0.999 89	1.280
1847.3	6.711	0.999 88	1.251
1847.4	6.711	0.999 87	$1.203 \times 10^{-4}$
1847.7	6.710	0.999 85	$9.930 \times 10^{-5}$
1847.8	6.710	0.999 84	9.148
1847.9	6.709	0.999 84	8.385
1848.0	6.709	0.999 84	7.669
1848.1	6.708	0.999 84	7.017
1848.2	6.708	0.999 84	6.435
1848.3	6.708	0.999 84	5.922
1848.9	6.706	0.999 85	3.986
1849.9	6.702	0.999 87	3.102
1850.0	6.702	0.999 87	3.085

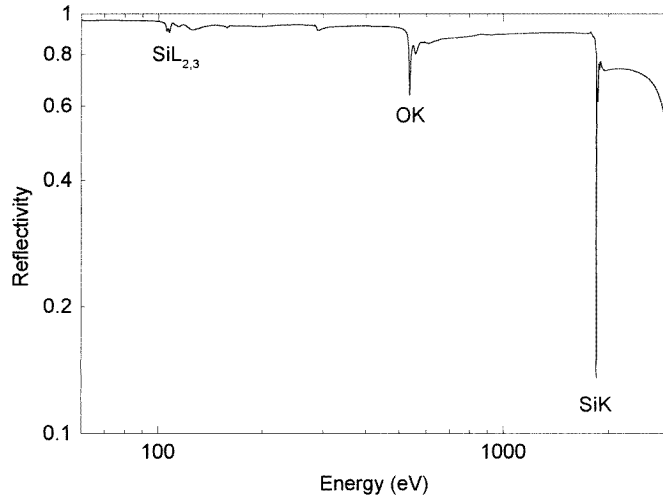
**Table 1.** (Continued)

eV	Å	<i>n</i>	<i>k</i>
1850.1	6.701	0.999 87	3.073
1850.2	6.701	0.999 87	3.067
1850.3	6.700	0.999 87	3.066
1850.4	6.700	0.999 87	3.068
1850.5	6.700	0.999 87	3.074
1851.6	6.696	0.999 88	3.289
1852.7	6.692	0.999 88	3.489
1853.6	6.689	0.999 88	3.509
1855.0	6.683	0.999 88	3.507
1900.2	6.525	0.999 88	1.975
1950.2	6.357	0.999 88	2.097
2000.2	6.198	0.999 89	1.928
2045.2	6.062	0.999 89	1.781
2095.2	5.917	0.999 89	1.634
2140.2	5.793	0.999 90	1.514
2190.2	5.661	0.999 90	1.394
2240.2	5.534	0.999 91	1.285
2285.2	5.425	0.999 91	1.196
2320.2	5.343	0.999 91	1.132
2370.2	5.231	0.999 91	$1.048 \times 10^{-5}$
2410.3	5.144	0.999 92	$9.859 \times 10^{-6}$
2460.3	5.039	0.999 92	9.149
2500.3	4.959	0.999 92	8.627
2550.3	4.861	0.999 93	8.025
2600.3	4.768	0.999 93	7.476
2655.3	4.669	0.999 93	6.923
2705.3	4.583	0.999 93	6.460
2755.3	4.500	0.999 94	6.059
2805.3	4.420	0.999 94	5.672
2850.3	4.350	0.999 94	5.354
2900.3	4.275	0.999 94	5.019
2945.3	4.209	0.999 94	4.750
2980.3	4.160	0.999 95	4.563
3000.3	4.132	0.999 95	4.462

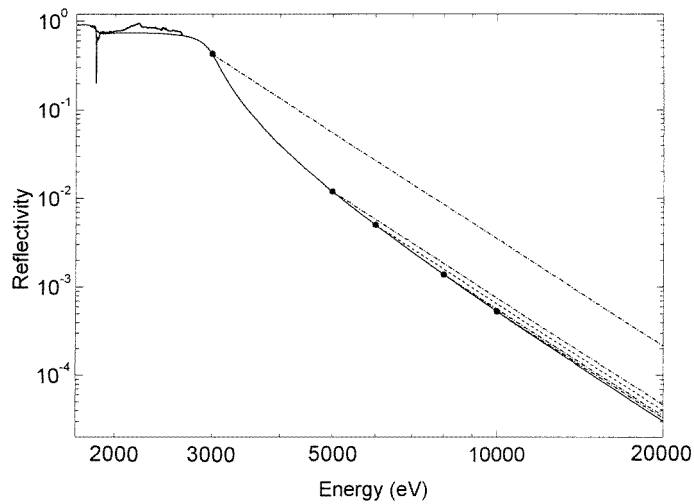
dispersion where the photon energy is far from the absorption edges. Then, the total atomic dipole moment is proportional to the average atomic factor of the medium. With this result we can use the data of the atomic scattering factor from the table of Henke [1] in the ranges of normal dispersion, specifically in the range 900–1800 eV aligned far from O K and Si K absorption edges.

The data were connected as follows. Using refined optical constants derived from the experimental spectrum measured at the grazing angle of 2° in the energy range 50–900 eV, the reflection spectrum at 0.6° was calculated. Unfortunately this operation is inevitable and is motivated by the special features of the experimental conditions in the soft-x-ray range. The calculated spectrum and the spectrum measured at 0.6° in the energy range 1800–3000 eV (figure 2) corrected for the surface roughness by equation (3*b*) were compared with the reflection coefficients calculated from the atomic scattering factor [1] in the regions of normal dispersion. For the smooth combination of the data, a fitting analysis varying the ratio  $\sigma^2/\sqrt{a}$  was used. The value of mass density was fixed and equal to 2.3 g cm<sup>-3</sup> derived in [14] and [15].

Figure 3 shows the reflection spectrum at  $\theta = 0.6^\circ$  in a wide energy region, including



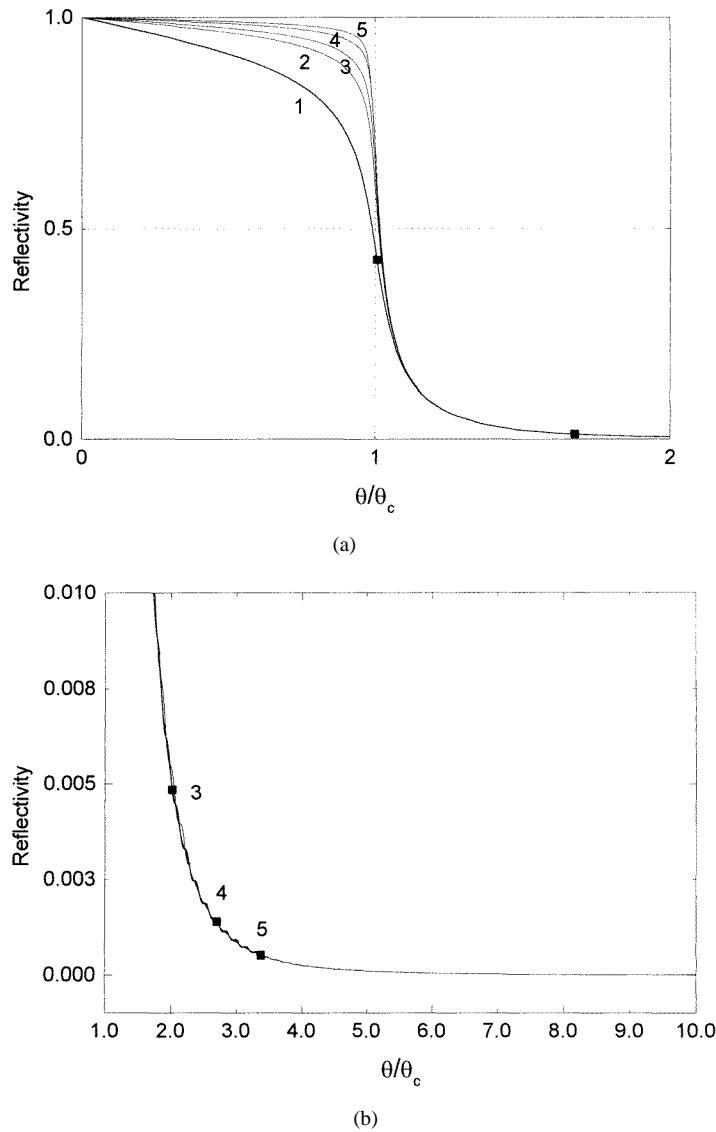
**Figure 3.** Reflection spectrum at  $\theta = 0.6^\circ$  in a wide energy region, including Si L<sub>2,3</sub>, O K and Si K absorption edges corrected for the surface roughness.



**Figure 4.** Spectral dependency of the reflection coefficient at  $\theta = 0.6^\circ$  in the energy region from 1.8 keV to 20 keV. The bold-faced curve denotes the experimental curve, the full curve the data based on the results of [1]; the dashed curves denote the extrapolation by the relation  $R(E) \sim E^{-4}$  from different separate energies indicated by circles.

Si L<sub>2,3</sub>, O K and Si K absorption edges corrected for the surface roughness.

Analysis of angular dependencies of the reflection measured at discrete points in the spectral range 50–3000 eV have provided control of the normalization of the reflection coefficients obtained. The extrapolation of  $R(\theta)$  to the point  $\theta = 0$  should exactly give  $R = 1$ . Although this point is experimentally inaccessible, the approximation performed allows one to examine the normalization of the experimental curves.

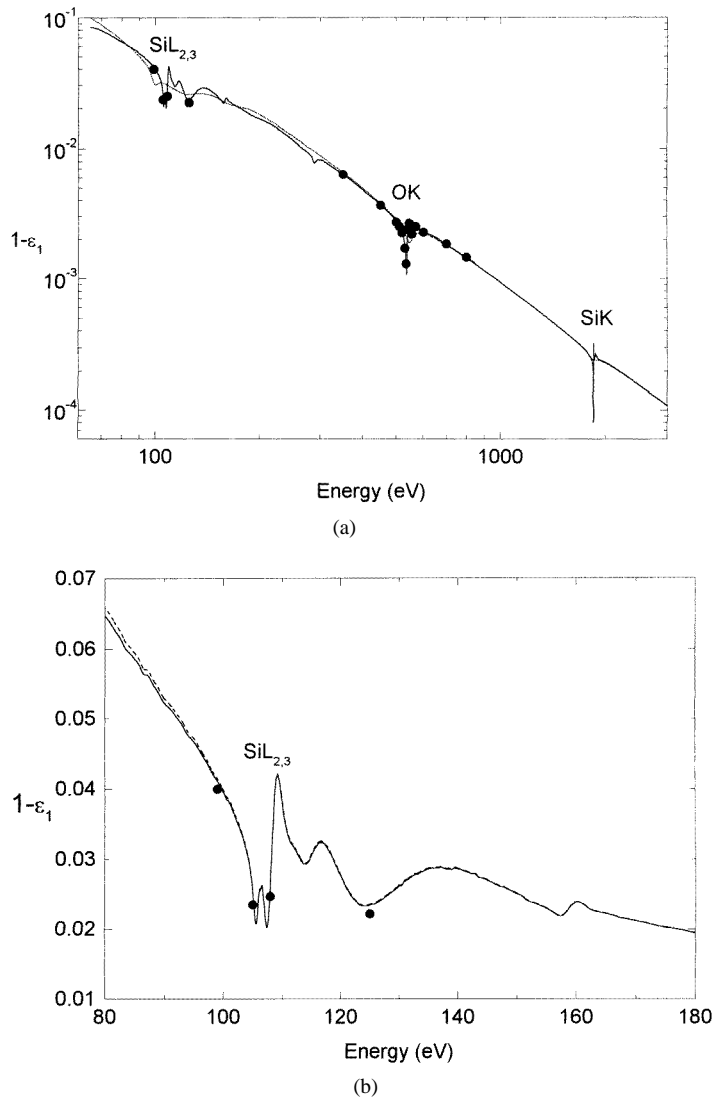


**Figure 5.** (a) Angular dependencies of the reflection coefficient at separated energies: 1, 3 keV; 2, 5 keV; 3, 6 keV; 4, 8 keV; 5, 10 keV. Squares identify the position of grazing  $\theta = 0.6^\circ$  in the angular curves. (b) A magnification of the region of small reflection coefficient values.

#### 4.2. Dispersion of the optical constants

As pointed out above, to give the optical constants by means of the Kramers–Kronig relation, extrapolation outside the experimental range is called for. In order to obtain a smooth connection of the experimental spectra with the extrapolation curve, one can use, according to our earlier investigation [14, 15] in the low energy range, the following extrapolation,

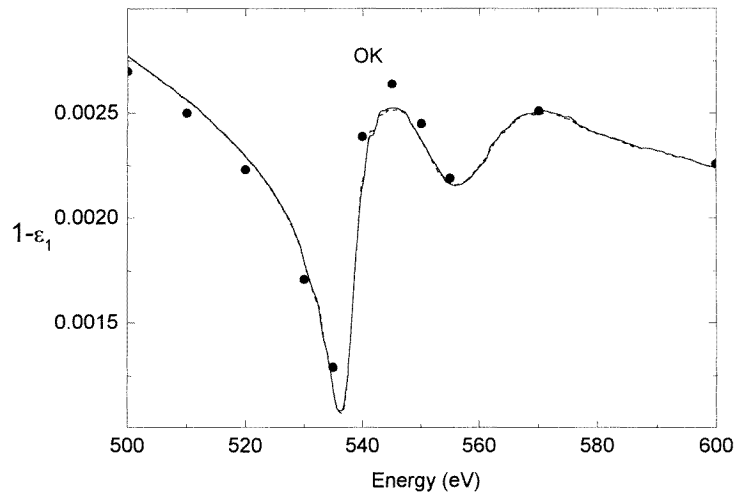
$$R(E) = R(E_1) + (1 - R(E_1)) \left(1 - \frac{E}{E_1}\right)^{1/2} \quad (4)$$



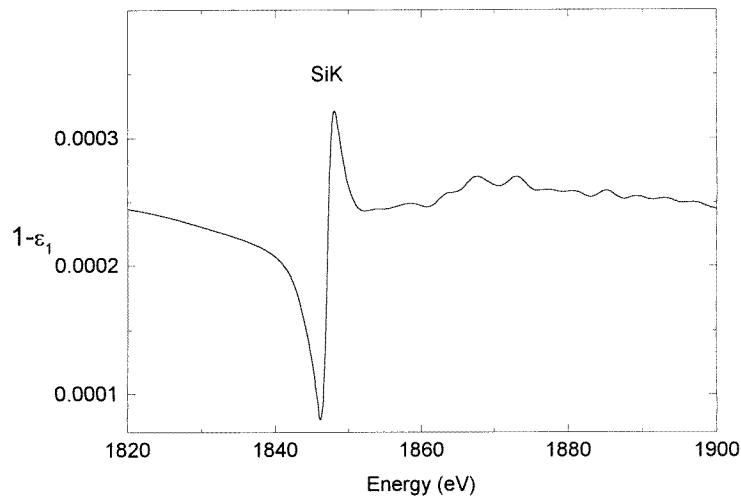
**Figure 6.** (a) Spectral dependency of the real part  $1 - \epsilon_1$  of the dielectric constant. The solid curve is the calculation from the reflection spectrum for a grazing angle  $\theta = 0.6^\circ$ ; the dotted curve is the calculation based on the results of [1]; circles are the data obtained from the angular dependent measurements [14]. (b) A magnification of the region around the  $SiL_{2,3}$  edge. (c) A magnification of the region around the  $O K$  edge. (d) A magnification of the region around the  $Si K$  edge. The dashed curve is the calculation from the reflection spectrum measured in the range 50–900 eV at the grazing angle  $2^\circ$ .

from the point  $E_1 = 50$  eV to  $R = 1$  at  $E = 0$ . In the high energy region, where the photon energy exceeds the ionization potential of the  $Si K$  edge, the law of absorption  $\mu(E) \sim E^{-3}$  is valid. Using Fresnel formulas and the fact that in the region of normal dispersion  $\delta/\lambda^2 = \text{const}$  (where  $n + ik = 1 - \delta + ik$ ) the relation  $R(E) \sim E^{-4}$  can be obtained. By this means, the spectrum was extrapolated according to the relation  $R(E) \sim E^{-4}$  from the point  $E_2 = 3000$  eV.

In the context of the preceding, the dispersion of optical constants was derived. The optical constants obtained at discrete energy points by means of analysis of angular dependencies



(c)

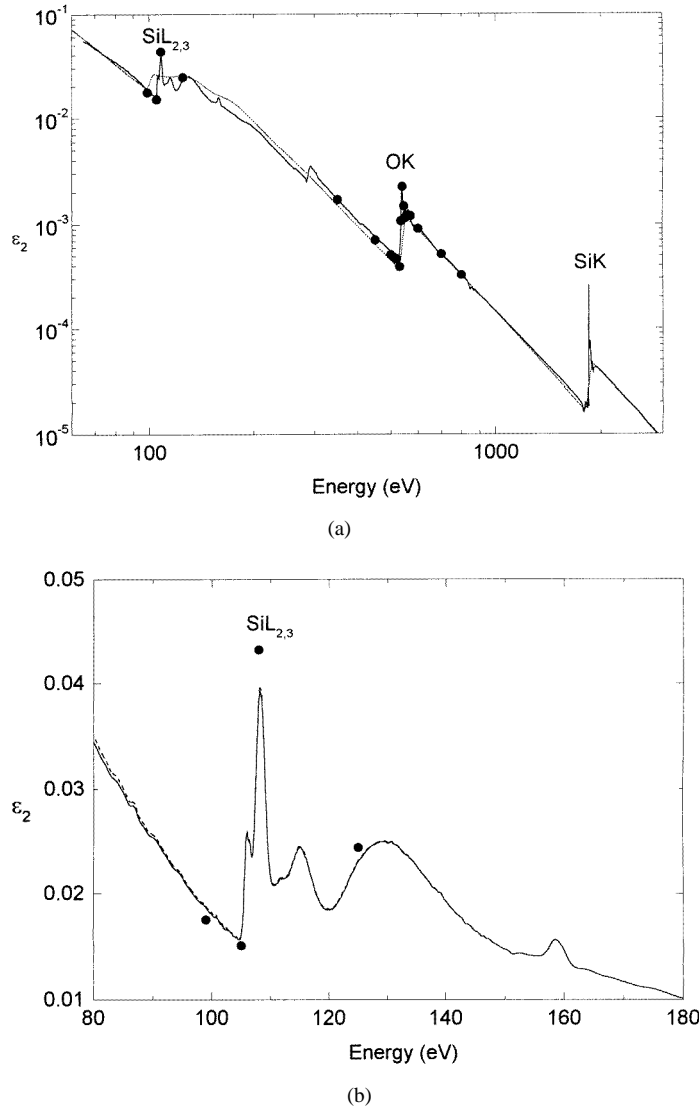


(d)

**Figure 6.** (Continued)

of the reflection coefficient from [14] were used to control over the optical constants calculated by the Kramers–Kronig integral. The data calculated in the frame of the above-mentioned extrapolation was found to be larger by about 80% as compared to controlled data.

In order to appreciate the cause of such huge discrepancies, let us call attention to the angular and spectral dependencies of the reflection coefficient at the energies larger than 3 keV. Because this energy range is aligned in the range of normal dispersion (far from absorption edges), the values of atomic factor from [1] are useful in the calculation of the reflection coefficients. Figure 4 shows the spectral dependency of the reflection coefficient at the grazing angle of 0.6° in the energy region from 1.8 keV to 20 keV (there is the experimental curve in the region 1.8 keV to 2.7 keV and there are the data based on the results of [1] for energies larger than 2.7 keV). The extrapolation from the relation  $R(E) \sim E^{-4}$  from different separated



**Figure 7.** (a) Spectral dependency of the imaginary part  $\epsilon_2$  of the dielectric constant. The solid curve is the calculation from the reflection spectrum for a grazing angle  $\theta = 0.6^\circ$ ; the dotted curve is the calculation based on the results of [1]; circles are the data obtained from the angular dependent measurements [14]. (b) A magnification of the region around the Si L<sub>2,3</sub> edge. (c) A magnification of the region around the O K edge. (d) A magnification of the region around the Si K edge. The dashed curve is the calculation from the reflection spectrum measured in the range 50–900 eV for a grazing angle  $\theta = 2^\circ$ .

energies is presented too. As will be seen from figure 4, the relation  $R(E) \sim E^{-4}$  breaks down for energies where the reflection coefficient varies only slightly (in the total external reflection region). The behaviour of the reflection coefficient is reasonably described by this relation only at high energies larger than around 8 keV.

Figure 5 shows the angular dependencies of the reflection coefficient at separated energies (these energies are marked on figure 4 by circles). Squares identify the position of the grazing

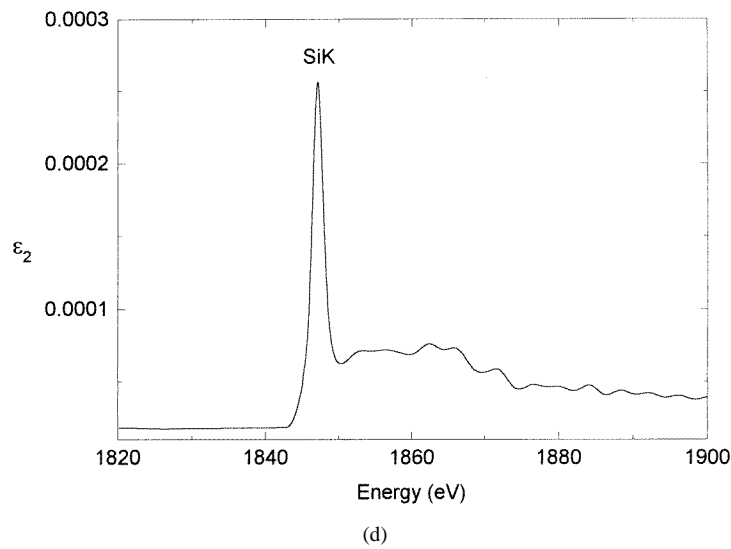
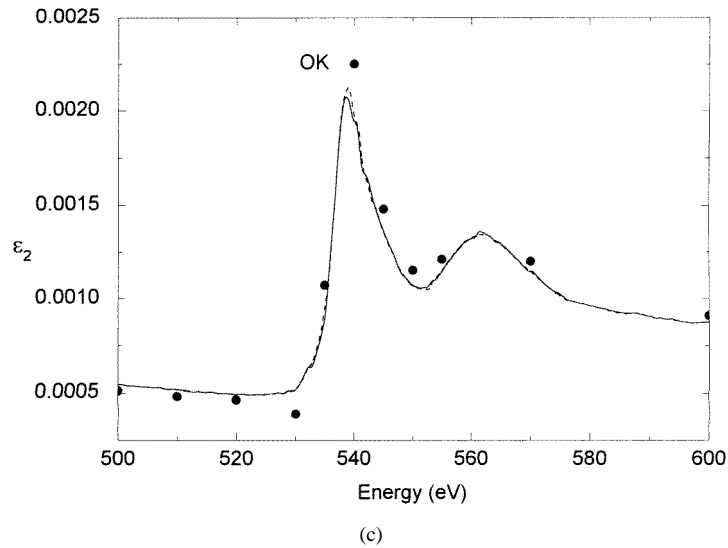


Figure 7. (Continued)

angle  $0.6^\circ$  in the angular curves. One can easily see that there are three extreme cases in the angular dependency of the reflection coefficient  $R(\theta)$ . In the first region, the reflection coefficient is great and varies only slightly (the total external reflection region). The second one is the region where the reflectivity decreases drastically. In the third region, the reflection is negligibly small for all energies. From figure 5, we notice that the reflection coefficient at the grazing angle  $0.6^\circ$  is brought into the third region for all energies larger than 8 keV. Because, for the energy 8 keV, the ratio  $\theta/\theta_c$  is about 2.5 at  $\theta = 0.6^\circ$ , one is inclined to think that the relation  $R(E) \sim E^{-4}$  holds for energies such that  $\theta_c < \theta/2$ .

The dispersion of optical constants was derived using extrapolation from different energy points from the relation  $R(E) \sim E^{-4}$  to consider the influence of the extrapolation on the value of optical constants.



It was found that the greatest relative error occurs when the extrapolation is carried out from the energy such that  $\theta = 0.6^\circ$  is in the second range (figure 5) and was in excess of 50%. Extrapolation carried out from energies larger than 8 keV gives practically the same values of optical constants.

Figures 6 and 7 show the calculated spectral dependencies of real ( $1 - \varepsilon_1$ ) and imaginary  $\varepsilon_2$  parts of the dielectric constant  $\varepsilon$  in the region 50–3000 eV using extrapolation carried out from 8 keV. Table 1 lists the calculated optical constants. We have elected to tabulate  $n$  and  $k$  because it is then an easy matter to obtain  $1 - \varepsilon_1 = n^2 - k^2$  and  $\varepsilon_2 = 2nk$  as well as reflectivity  $R$ .

From figures 6 and 7, we notice that a consideration of the Si K absorption edge does not affect the values of optical data near Si L<sub>2,3</sub> and O K absorption edges. Brief mention should be made of a peak at about 300 eV. Analysis of the calculated spectra as well as reflection spectra allows us to connect this structure with carbon. Analysis of the calculated optical data in the region 300–550 eV points to the fact the values derived from spectral dependencies of reflection using Kramers–Kronig analysis are higher than those predicted from data based on the results of [1] and from angular dependencies of reflection in this energy region.

## 5. Conclusions

In this paper, the optical constants of amorphous SiO<sub>2</sub> have been calculated by the Kramers–Kronig analysis in the continuous spectral region including Si L<sub>2,3</sub>, O K and Si K absorption edges from the reflection spectra measured using synchrotron radiation. It has been found that a consideration of the Si K absorption edge does not affect the values of optical data near Si L<sub>2,3</sub> and O K absorption edges.

It was demonstrated that for the extrapolation of the experimental curve in the high energy region, where the photon energy exceeds the ionization potential of the Si K edge, the relation  $R(E) \sim E^{-4}$  can be used for energies such that  $\theta_c < \theta/2$  at small angles. It may be assumed that this criterion is valid for large angles. According to this criterion, the point of the beginning of extrapolation will move in the direction of decreasing energy as the grazing angle increases. With the growth of the angle  $\theta$ , the energy region needed to measure the reflection spectrum will be narrowed.

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